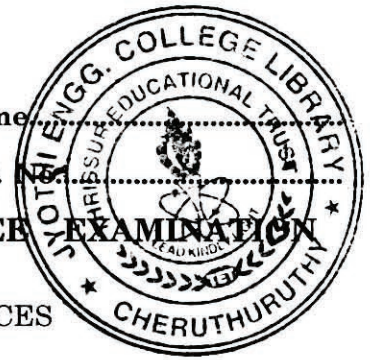


C 40953

(Pages : 2)

Name

Reg. No.



FOURTH SEMESTER B.TECH. (ENGINEERING) DEGREE EXAMINATION
APRIL 2013

EC 09 406/PTEC 09 405—SOLID STATE DEVICES
(2009 Scheme)

(Regular/Supplementary/Improvement)

Time : Three Hours

Maximum : 70 Marks

Part A

*Answer all questions.
Short answer questions.*

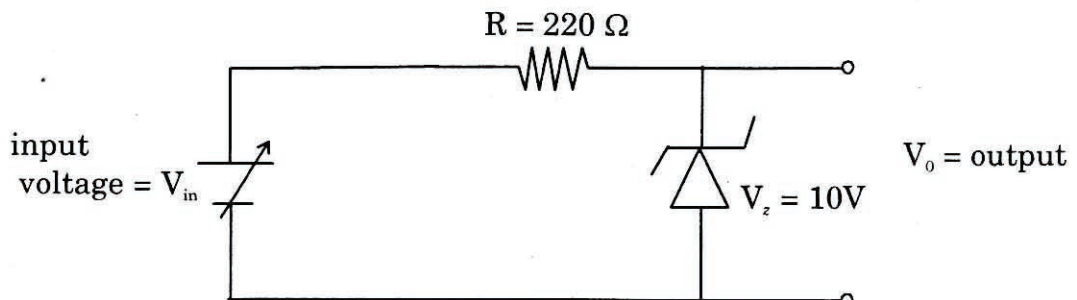
1. What is Fermi level ?
2. State Einstein's relation.
3. Why JFET is called voltage controlled device ?
4. What is base-width effect in BJT ?
5. Write in brief the significance of threshold voltage of MOSFET.

(5 × 2 = 10 marks)

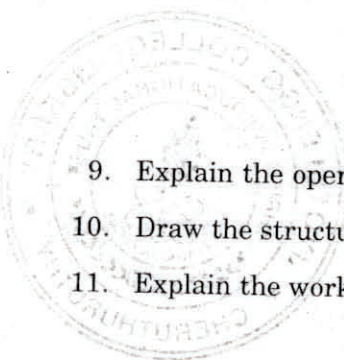
Part B

Answer any four questions.

6. Derive the expression for electron and hole concentration of semiconductor doped with trivalent impurity.
7. Derive the expression for diffusion current in semiconductors.
8. A constant 10V Zener diode with $R = 220 \Omega$ as shown in the circuit below has $I_{\min} = 0.25 \text{ mA}$ and $I_{\max} = 100 \text{ mA}$. Find the range of input voltage over which the output is regulated.



Turn over

- 
9. Explain the operation of n-channel JFET.
 10. Draw the structure of power MOSFET and explain its operation.
 11. Explain the working of MOS capacitor with diagram.

(4 × 5 = 20 marks)

Part C

12. (a) Explain with neat diagrams direct and indirect bandgap in semiconductors.

Or

- (b) Derive the expression for conductivity and mobility in intrinsic semiconductors.

13. (a) Derive the expression for space-charge capacitance in PN junction.

Or

- (b) Explain the construction, working and characteristics of tunnel diode with neat diagrams.

14. (a) Explain the construction and working of hetero junction bipolar transistors.

Or

- (b) Explain the working of p-channel JFET and its drain and transfer characteristics.

15. (a) Explain the construction, working and characteristics of p-channel E-MOSFET with diagrams.

Or

- (b) Explain the different methods of turning-off SCR.

(4 × 10 = 40 marks)